



[Translation]

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To whom it may concern:

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**Certification of the Supply Assurance Plan for Sputtering Targets for Semiconductors**  
**by the Ministry of Economy, Trade and Industry**

JX Advanced Metals Corporation (President: Hayashi Yoichi, hereinafter “the Company”) announced today that the Company has received certification from the Ministry of Economy, Trade and Industry for its supply assurance plan concerning sputtering targets for semiconductors, as outlined below.

**1. The Certified Supply Assurance Plan**

As part of the support measures under the Economic Security Promotion Act aimed at ensuring the stable supply of semiconductors and related products, a portion of the capital investment plan to be implemented by the Company at the planned new Hitachinaka Factory has been certified. As a result, the Company is expected to receive a subsidy of up to approximately 2.2 billion yen.

In the JX Advanced Metals Group Long-Term Vision 2040, the Company set forth its commitment to contributing to social development and innovation as a global leader in advanced materials. To realize this vision, the Company has acquired a large-scale site in Hitachinaka City, Ibaraki Prefecture, and is proceeding with the construction of a new factory that will serve as a new core base for its advanced materials business. This factory will primarily focus on semiconductor materials, including sputtering targets for semiconductors, for which future demand growth is anticipated.

Sputtering targets for semiconductors are thin-film materials used in the formation of wiring patterns and other processes, and are essential to the semiconductor supply chain. The Company’s sputtering targets for semiconductors, particularly those for advanced semiconductors, hold a significant global market share and play a vital role in the global semiconductor supply chain. By steadily expanding production capacity for these products at the new Hitachinaka Factory, the Company will fulfill its supply responsibilities to both domestic and international semiconductor supply chains.

The Company will continue to promote initiatives aimed at transforming into a technology-oriented company as outlined in the JX Advanced Metals Group Long-Term Vision 2040, striving to become a global enterprise that contributes to social development and innovation through advanced materials.

**Overview of Support Measures**

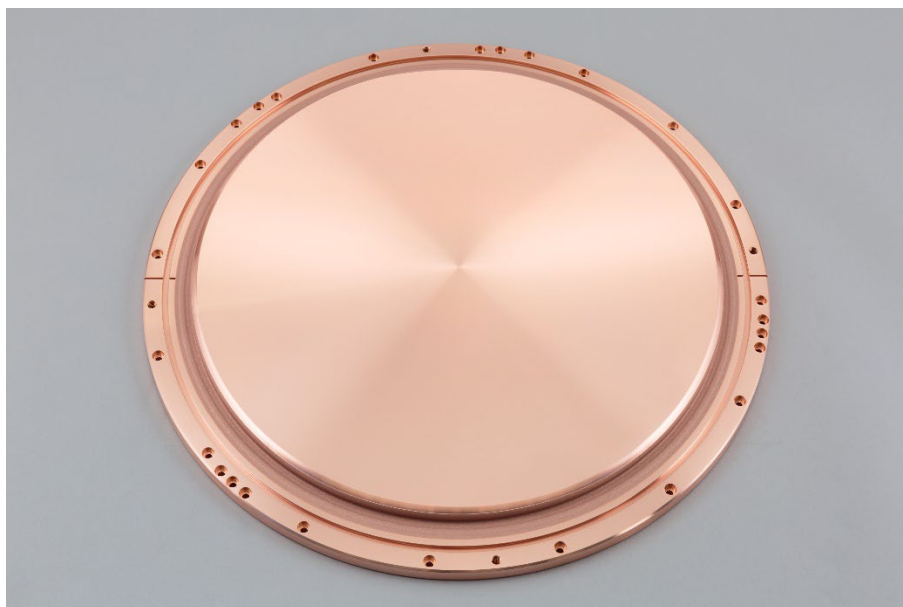
Production Site	Planned new Hitachinaka Factory (Hitachinaka City, Ibaraki Prefecture)
Details	Expansion of production capacity for sputtering targets for semiconductors
Required Funding	Approx. 6.6 billion yen (Maximum subsidy: approx. 2.2 billion yen)

## 2. Future Outlook

The impact on the consolidated financial results for the fiscal year ending March 2026 is expected to be minimal.

End

<Reference>



Sputtering target for semiconductors